



PATENT APPLICATION  
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80691

Hajime NAKAO *et al.*

Appln. No.: 10/809,389

Group Art Unit: 1752

Filed: March 26, 2004

Examiner: WALKE, AMANDA C

For: POSITIVE RESIST COMPOSITION

STATEMENT

Commissioner for Patents  
Alexandria, VA 22313-1450

Sir/Madam:

I, Hidetaka Ota, residing at 7-13, Nishi-Shimbashi 1-chome, Minato-ku,  
Tokyo, Japan hereby state that:

I well understand the Japanese and English languages and attached is  
an accurate English translation made by me of Japanese Patent Application No.  
2003-89021, filed March 27, 2003.

Date:

December 11, 2006

Name:

  
Hidetaka Ota